

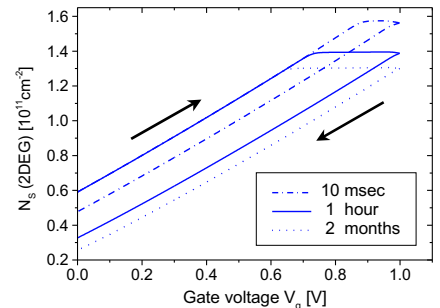
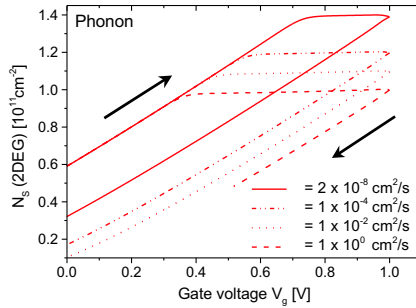
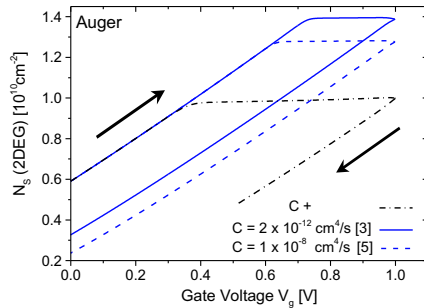
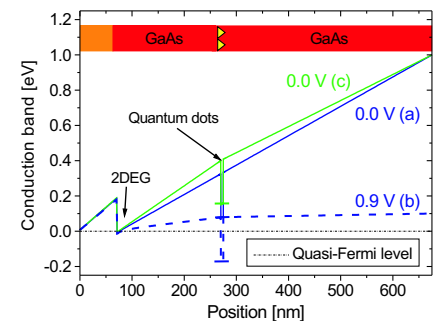
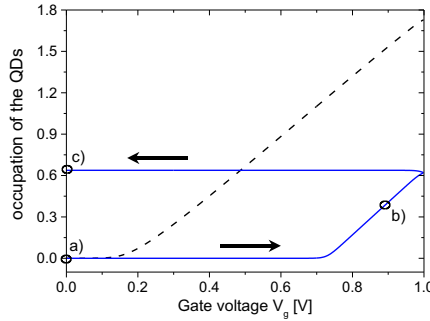
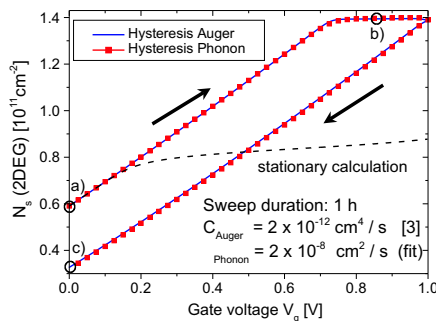


Dynamics of charge storage in quantum dot devices

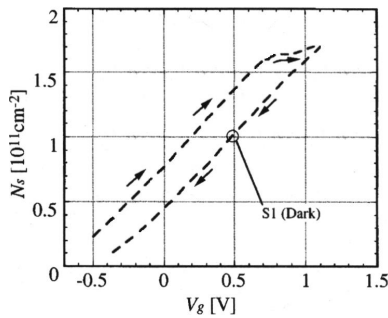


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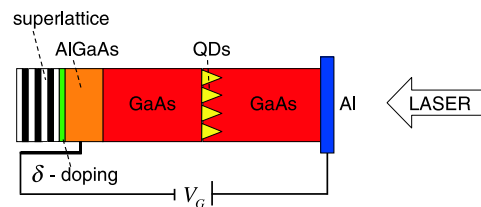
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Experiment



GaAs/n-AlGaAs field effect transistor



77 K, dark, 1 h sweep duration

Model

Poisson equation

$$\frac{\partial}{\partial z} \left(\epsilon \frac{\partial \phi}{\partial z} \right) = -e (n - N_D)$$

Continuity equation

$$\frac{\partial n}{\partial t} + \frac{\partial}{\partial z} (n v) = f(n, n_{QD}^{2D}, n_{QD}^{1D})$$

Electron capture and emission rate (QD)

$$f(n, n_{QD}^{2D}, n_{QD}^{1D}) = C_A n^2 + C_P n_{QD}^{2D} + C_E n_{QD}^{1D}$$

Conclusion

- Auger vs. Phonon -

- Auger process [3] exactly reproduces necessary electron emission and capture rates, suitable for fast and for slow dynamics
- experimental data yields fast dynamics for high charge densities and slow dynamics for low densities. As the Auger process depends quadratically on those densities it suits both - slow and fast dynamics - while the phonon processes depend linearly on the densities and therefore only can explain slow or fast dynamics [4]

- numerical simulations in perfect agreement with experimental results
 - in order to reproduce the experiment with phonon processes one has to use an extremely small capture rate ($10^{-4} \text{ cm}^2/\text{s}$)
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 [3] A. V. Uskov et al., Appl. Phys. Lett. 72, 58 (1998)
 [4] R. Heitz et al., Phys. Rev. B 56, 19435 (1997)
 [5] S. Raymond et al., Phys. Rev. B 61, 16331 (2000)